

Supporting Information

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Near-Infrared Multilayer MoS₂ Photoconductivity-Enabled Ultrasensitive Homogeneous Plasmonic Colorimetric Biosensing

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METHODS

Chemicals: We purchased gold nanoparticle (gold nanosphere (AuNPs, d = 50nm) from Tedpella, 10-Carboxy-1-decanethiol (C-10) and Albumin from bovine serum (BSA) from Sigma Aldrich, 1-ethyl-3-[3-dimethylaminopropyl] carbodiimide (EDC) and/ Nhydroxysuccinimide (NHS) from Thermo Co., respectively. We purchased CEA protein and Anti-CEA antibody from abCAM and polydimethylsiloxane (PDMS) elastomer and curing agent from Coring, respectively. Nano pure deionized (DI) water (18.1 MΩ-cm) was produced in-house.

Multilayer MoS₂ fabrication: We used a micro-printing method to fabricate a multilayer-MoS₂ photoconductive nanosheet channel on a SiO₂/Si substrate.^[1-5] The printed MoS₂ nanosheet channel had a thickness of ~ 14.5 nm, showing a sufficient photoresponsivity at $\lambda = \sim$ 650 nm. A Ti (5 nm) - Au (50 nm) electrode pair providing as the drain and source contacts for the MoS₂ channel was subsequently fabricated using photolithography, which was followed by metal deposition and lift-off. The resulting channel length and width were ~ 5 and ~ 10 µm, respectively. We characterized the topography of the MoS₂ nanosheet channel using an atomic force microscope (Bruker ICON AFM). Tapping mode scan (scanning speed: 0.1 µm/sec) was performed using an AFM tip with the cantilever resistivity ranging from 0.010 to 0.025 Ω cm in antimony n-doped silicon. We post-processed the obtained topographical data using commercial software (Nanoscope Analysis). The fabrication of photodetectors made of these MoS₂ channels followed the same lithographical patterning and etching processes in Figure S2.

Noise Characterization of MoS₂: Assuming the shot noise of photodetectors as the main noise source, the measured noise current i_N is defined as $i_N = (2e * I_{dark})^{1/2}$, where e is the electric charge and I_{dark} is the dark current. We obtained noise power spectral density (i_N^2 /Hz) curves for a commercial CdS (Cadmium Sulfide) photodetector, a MoS₂ channel, and the analyzer

system, respectively. Every measurement for the photodetectors was performed under the dark condition at $V_{DS} = 0.2$ V with no gate bias applied. The lowest measurable noise level of the system was confirmed by repeating measurements with suspended probe tips. The noise spectral density curve of the system shows a flat spectral noise density (i.e., a clear 1/f-noise component), which indicates the noise floor of the measurement system. We performed all measurements using a semiconductor analyzer (Keithley 4200A).

Gold nanoparticle functionalization with antibody: At first, we centrifuged a solution suspending gold nanospherical particles (AuNPs) (0.2 nM) three times at 5,000 rpm for 10 min and washed the AuNPs in D.I. water to remove excessive structure direction agents (citrate) from the solution. Subsequently, we functionalized the AuNPs with thiolated alkane 10-Carboxy-1-decanethiol (HS-(CH₂)10-COOH) using a self-assembly method (SAM). In this process, AuNP colloidal solution was first incubated in 1mM of thiolated alkane 10-Carboxy-1-decanethiol (HS-(CH₂)₁₀-COOH) overnight. Then, the antibody was linked to the –COOH functional group formed on the AuNP surface by means of standard 1-ethyl-3-[3dimethylaminopropyl] carbodiimide / N-hydroxysuccinimide (EDC / NHS) coupling chemistry. Here, we first washed the -COOH functionalized AuNPs and loaded these AuNPs into a mixture of 0.4 M EDC and 0.1 M NHS at a 1:1 volume ratio in a 0.1 M EDC solution to activate the AuNP surface. We loaded a solution of primary CEA antibodies diluted from 100 to 10 µg/mL in 1x PBS into the micro-tube holding the solution of the AuNPs functionalized above and incubated it for 60 min. To suppress fouling of the AuNP surface due to non-specific binding, we treated the prepared antibody-AuNP conjugates with 1% BSA in 1x PBS in blocking buffer and incubated the whole system for 20 min. Before the assay measurement of CEA, the antibody-AuNP particles were thoroughly washed three times to remove any excessive solutions or molecules using 20μ L of 1×PBS. In addition, we obtained the extinction spectrum of the AuNP colloidal solution before and after the functionalization using a UV-VIS

spectrometer (Agilent 8453 G1103A Spectrophotometer) to confirm the AuNP functionalization.

Assembly of multilayer MoS₂ channel-integrated colorimetric reader device: We prepared a micro-chamber on a thin SiO₂ layer (Thickness = 250 μ m) and the multilayer-MoS₂ channel on a silicon substrate, individually. We attached a medical grade double-sided tape (3M, thickness = 100 μ m) onto the drain and source electrodes of the multilayer-MoS₂ channel. Next, we assembled them by placing the micro-chamber on the multilayer-MoS₂ channel along the marks under a stereo microscope (Olympus SZ61 Stereo Microscope) with a gentle press to ensure the attachment. After the assembly, we inspected the alignment using an optical microscope (Olympus SZ61 Stereo Microscope) and ensured the attachment between the micro-chamber and the multilayer-MoS₂ photodetector by flipping the assembled structure.

Experimental setup for the assay: In our homogenous plasmonic colorimetric assay, we mixed a biofluid sample with the plasmonic probe, loaded the mixture into the micro-chamber of the device, and measured photo current using an HP-4145B semiconductor parameter analyzer. Here, we used a 650 nm laser (power density, 2.5 mW/cm²) to characterize the photo response performance of the devices. For the control study, we also used a 532 nm layer power density (2.5 mW/cm²). We also measured the power density using a conventional power and wavelength meter (OMM-6810B-100V, Newport). The power density was tuned by neutralized density filter.

Gold standard ELISA: A 96-well plate of CEA ELISA kit was developed in our laboratory as described previously.^[6] Briefly, each well of a 96-well plate was coated with 0.2 µg of anti-CEA antibody (capture antibody) and incubated overnight at 4°C, then it was blocked with a blocking buffer (Thermo Scientific, Rockford, IL, USA) at room temperature (RT) for 2 h. We

loaded sample solution onto the prepared plate. After 4 times of washing, anti-CEA antibody (1:3000 diluted) was added as detecting antibody and incubated at room temperature for 2 h. Following 4 times of washing, anti-peroxidase-labeled secondary antibody (1:50000 diluted) was incubated in the wells at room temperature for 1 h. After removing extra secondary antibodies with 4 times of thorough washing, the plate was developed with 3, 3', 5, 5'-Tetramethylbenzidine (TMB) for 20 minutes in dark, followed by dispensing a stop solution. CEA levels were determined using a plate reader at $\lambda = 450$ nm.

Electromagnetic field simulation: We conducted a finite element analysis (FEA, COMSOL Multiphysics software) to predict the near-field electromagnetic fields around a dispersed AuNP and assembled AuNPs by solving Helmholtz wave equation. We constructed hybrid mesh structures for the AuNPs and their interparticle nanogap to fit their round shapes. In this analysis, we assumed that the relative permeability and complex permittivity of gold were 1 and $\varepsilon_r = f(\lambda)$, respectively. In addition, the model assumed perfect absorption at the outer boundary to minimize spurious reflections by setting a perfectly matched layer and an integration layer in a concentric space. According the SEM images in Figure 3, we defined the represented dimensions of the AuNP and the nanogap to be d = 50 nm and g = 1 nm, respectively. The simulation shows that the surface plasmon of the AuNP is strongly excited at $\lambda = 532$ nm and $\lambda = 650$ nm.

Human whole-blood and serum samples: Human blood samples were drawn from a healthy donor after obtaining informed consent according to an Institutional Review Board (IRB)-approved protocol (protocol HUM00115179/UMCC 2016.051). Some of specimens were collected and aliquoted in ethylenediaminetetraacetic acid tubes, and processed to obtain plasma and serum within 3 h.

Standard artificial saliva and urine: We used artificial saliva by dissolving 5 mM of NaCl, 1 mM of CaCl₂, 15 mM of KCl, 1 mM of citric acid, 1.1 mM of KSCN, and 4 mM of NH₄Cl in distilled water. The pH of artificial saliva was adjusted to 6.7, which is the average pH of healthy human saliva⁴⁹⁻⁵¹. We also purchased artificial urine from Carolina Biological Supply Company (Burlington, NC).



Table S1	. Detection	performances	of commercialized	human	CEA ELISA kits.
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Commercialized human CEA ELISA	LOD	Time to results	Volume
Invitrogen	200 pg/mL	4 hr 45min	100 µL
Boster	20 pg/mL	8 hr	100 µL
Sigma-Aldrich	200 pg/mL	5 hr	100 µL
Abcam	200 pg/mL	5 hr	100 µL
Raybiotech	200 pg/mL	5 hr	100 µL



Figure S1. Micro-printing-based MoS₂ pattern fabrication. i) Preparing a bulk MoS₂ stamp, ii) Transferring the bulk stamp onto a Si substrate coated with a polymeric fixing layer, iii) Performing nanoimprint to push the bulk stamp against the polymeric fixing layer, iv) Applying shear exfoliation, v) Forming exfoliated MoS₂ patterns, vi) Removing the polymeric fixing layer, vii) Illustration of the layered structure of the fabricated MoS₂ pattern.



Figure S2. Time-domain root-mean-square (RMS) noise values of MoS_2 photoducucting channels. Representative data of (a) Pristine 3 nm-thick MoS_2 channel, (b) Pristine 14 nm-thickness MoS_2 channel, and (c) O_2 plasma treated 14 nm-thick MoS_2 channel.



Figure S3. AFM (a) images and (b) thickness profiles of MoS₂ layers i) 2.5, ii) 7.5, iii) 12.5, and 25 nm.



Figure S4. Multilayer MoS₂ channel photocurrent as a function of illumination power. The photocurrent between the source and drain of the channel at the source-drain voltage of 1V increases almost linearly with the incident light power ranging from 25 to 60 mW.



Figure S5. Fabrication steps of multilayer MoS₂ channel-integrated colorimetric reader device. i) Thermally growing a SiO₂ layer on Si substrate, ii) Synthesizing a large-area (2 cm \times 3cm) MoS₂ blanket layer onto the SiO₂/Si substrate by chemical vapor deposition (CVD). iii) Spin-coating photoresist (SPR 220) at 4,000 rpm and soft-bake the substrate at 115 °C for 1 min to remove the solvent. Patterning the photoresist layer by UV light exposure using a mask aligner (MA6, Karl Suss) and develop it. Then, loading the substrate into a plasma etching chamber (Xactix XeF₂), etching the exposed MoS₂ with 2 Torr XeF₂ for 10 second, and stripping off the photoresist to form the MoS₂ channel pattern. iv) Depositing and patterning the second photoresist layer. v) Depositing a Ti (5 nm)/Au layer (50 nm) on the patterned second photoresist layer using an electron beam (e-beam) evaporation system (Enerjet Evaporator). vi) Lifting off the photoresist to pattern a pair of electrodes that provide drain and source contacts for the MoS₂ channel (length: 1 μ m, width: 10 μ m). vii) Placing a SiO₂ substrate (t = 100 μ m) on top of the banks of the Au electrodes. viii) attaching a soft lithographically molded PDMS layer whose surface is treated by O_2 plasma at P = 18 W for 2 min to the SiO₂ substrate. The assembly of the micro-well originally created in the PDMS layer and the SiO₂ substrate forms the colorimetric reaction micro-chamber.



Figure S6. *I-V* curves of multilayer MoS₂ channel-integrated colorimetric reader device loaded with PBS, WB, and Urine with excitation illumination at (a) $\lambda = 530$ nm and (b) $\lambda = 650$ nm. The photocurrent of the MoS₂ photodetector channel I_{ph} was measured while sweeping the source-drain voltage from 0 to + 1 V for PBS, WB, and Urine samples unmixed with the antibody-AuNP solution and loaded to the micro-chamber of the reader device. The used illumination power was P= 2.5 mW for both (a) and (b). The smaller I_{ph} values at $\lambda = 530$ nm for WB and Urine are due to light absorption in those biofluids. In contrast, the I-V curves show small differences between PBS, WB, and Urine at $\lambda = 650$ nm, which implies small light absorption in WB and Urine in the NIR region.



Figure S7. *I-V* curves of multilayer MoS₂ channel-integrated colorimetric reader device for various CEA concentrations with excitation illumination (a) $\lambda = 530$ nm and (b) $\lambda = 650$ nm. These I-V curves were used for calibration of the plasmonic colorimetric biosensing assay of CEA in WB. The used excitation illumination power was P= 2.5 mW for both (a) and (b). As expected from the data in Fig. S6, the curves at $\lambda = 530$ nm show the weak photoresponse of the device due to light absorption in WB.

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